

Spectroscopy and Photodissociation of Dimethylzinc in Solid Argon. 1. Vacuum UV Luminescence Detection/Synchrotron Radiation Photolysis

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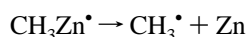
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Absorption spectra of thin-film DMZ/Ar samples, prepared by condensing gaseous mixtures of dimethylzinc (DMZ) with argon at 12 K, were recorded in the region of the first dissociative absorptions of DMZ centered in the gas phase at 200 nm. Large blue shifts are observed in the matrix spectra which can be related to the Rydberg-like characteristics of these excited states of DMZ. The photochemistry of DMZ in an argon matrix was investigated either by subjecting samples to undispersed synchrotron irradiation using a quartz filter to select a wavelength range above 155 nm or to wavelength-specific irradiation. Steady-state and time-resolved luminescence spectroscopy of the dissociation products isolated in solid argon indicate the existence of atomic zinc strongly perturbed by a methyl radical in freshly photolyzed samples, which yields truly isolated atomic zinc upon annealing to 33 K. Dissociation threshold measurements indicate a barrier of 25 kcal/mol for direct cage escape of atomic zinc in the Ar lattice. The increased intensity of Zn(³P₁)/Ar emission observed in photolyzed DMZ/Ar samples relative to pure Zn/Ar samples is explained in terms of the enhanced ISC of atomic zinc in the presence of hydrocarbon species in the former samples. This has been shown by co-deposition of atomic zinc with Ar doped with CH₄ and C₂H₆.

I. Introduction

Dimethylzinc belongs to a class of organometallic molecules known collectively as the dialkylmetals (R₂M), where R = CH₃, C₂H₅, ..., and M = Zn, Cd, or Hg, whose characteristic of greatest technological significance is their photodissociation in the gas phase, producing metal atoms. The “direct writing technique”, for example, a routine method utilized in the electronics industry for writing microcircuits on semiconductor materials,¹ relies on the production of atomic zinc using a focused UV laser to dissociate dimethylzinc. As a result of its technological importance, the UV spectroscopy² and photodissociation of DMZ in the gas phase^{3–5} and in molecular beams⁶ have been investigated by several groups, but to date, no work has been done in the solid state. In this and the following paper in this issue, the spectroscopy and photodissociation of DMZ isolated in solid Ar is examined with vacuum UV luminescence and FTIR absorption spectroscopies, respectively.

The photodissociation mechanism of DMZ in the gas phase has been examined in detail,^{4–6} leading to the proposal of the following stepwise mechanism for the production of atomic zinc:



Vibrationally excited methylzinc and methyl radicals are produced after one UV photon absorption by DMZ, leading to the bent, first excited state and the linear, second excited electronic state.⁵ The nascent methylzinc radical immediately dissociates in the gas phase due to excess vibrational energy.

The gas-phase work of Strausz and co-workers³ and more recently Jackson,⁴ in which methylzinc radicals were produced by the photolysis of dimethylzinc in the presence of a buffer gas, demonstrated that the yield of methylzinc radical increased with increasing buffer gas pressure at the expense of zinc atom production. Miller and co-workers⁷ have recently exploited this behavior to produce methylzinc radical in a supersonic jet by laser photolysis of dimethylzinc under the high-collision conditions present in the throat of the expansion. Cooling and, hence, stabilization of methylzinc radical were facilitated by further expansion in the jet, allowing high-resolution spectroscopic analysis⁷ of the ultracold methylzinc radical.

The vibrational relaxation trends exhibited in the gas phase work would indicate that the methylzinc radical should be efficiently stabilized in the solid. On this basis, it might then be expected that the photodissociation of DMZ in the solid would lead predominantly to the formation of methylzinc and a methyl radical. On the other hand, could geminate recombination arising from “cage effects” minimize the permanent production of such reactive radicals in the solid? Using IR spectroscopy in conjunction with steady-state and time-resolved luminescence spectroscopy as sensitive probes of dissociation, identification of the fragments in the cryogenic matrix will be used to answer the questions raised above. In addition, details of the vacuum UV and IR spectroscopy of DMZ and its photodissociation products in solid argon are presented in this and the following papers in this issue,⁸ respectively.

The format of this paper is as follows. In the first part, the vacuum UV absorption spectroscopy of matrix-isolated DMZ in Ar is presented. The photochemical fragments produced with synchrotron radiation photolysis are examined with UV luminescence spectroscopy. Assignments of the atomic and molecular photodissociation products of DMZ are then made from annealing experiments in conjunction with the FTIR study presented in the succeeding paper.⁸ From comparisons with

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the behavior observed in pure Zn/Ar samples and Zn/hydrocarbon/Ar samples, assignments of the fragments have been established. On the basis of the spectral assignments of the photochemical products, the dissociation mechanism of DMZ in solid Ar is discussed and compared to the gas phase in the final section.

II. Experimental Section

Steady-state and time-resolved optical measurements were conducted, as described previously,⁹ at the HIGITI experimental station in HASYLAB at DESY, Hamburg, using synchrotron radiation (SR) optimized in the vacuum UV spectral region from the W3 Mini-Wiggler of the DORIS III positron storage ring. Absorption spectra were recorded in the region of the $B \leftarrow X$ and $A \leftarrow X$ dissociative absorptions of DMZ, centered at 200 nm in the gas phase,⁵ by scanning with a 1 m normal incidence-modified Wadsworth monochromator and using a sodium salicylate converter and an XP2020 photomultiplier tube for photon detection.

Steady-state (emission and excitation) luminescence measurements were made with a secondary monochromator, using either a 0.4 m Seya-Namioka monochromator for measurements in the vacuum UV and near-UV regions or a 0.2 m Acton Research Corporation Type VM 502 monochromator for the UV-visible region. A Hamamatsu MCP 1645U-09 microchannel plate and a Hamamatsu R 943-02 photomultiplier tube were used as photon detectors on the Seya-Namioka and ARC monochromators, respectively. The detection system was operated in the single-photon-counting mode, allowing the measurement of emission decay curves, as described elsewhere,⁹ with time correlation of the pulsed synchrotron radiation, viz., time-correlated single photon counting (TCSPC). Sample annealing was achieved with a heater mounted on the cold tip of the liquid He cryostat, and temperatures were measured using a Lakeshore Cryotronics silicon diode. During sample annealing, a Balzers QMG 112A quadrupole mass spectrometer was used to detect and identify the gases evolving from the photolyzed DMZ/Ar samples.

The photochemistry of DMZ in the cryogenic matrix was investigated by subjecting the samples to either wavelength-selected irradiation or to irradiation with undispersed synchrotron light (achieved by setting the primary monochromator to zero order) using a quartz optical filter to select wavelengths longer than 155 nm.

III. Results

A. Electronic Absorption Spectroscopy. An absorption spectrum recorded in the ultraviolet spectral region at 8 K for a freshly deposited DMZ/Ar sample having a dilution ratio of 1/1000 is shown in the upper panel of Figure 1. A broad featureless band centered at 183 nm and a weaker shoulder extending up to 220 nm are observed. These profiles resemble the absorption profile observed in the gas phase,⁵ shown in the lower panel of Figure 1, but are considerably blue-shifted in the gas-phase $B \leftarrow X$ absorption centered at 204 nm and the $A \leftarrow X$ electronic transitions extending up to 240 nm. Knowing the DMZ/Ar dilution ratios and the sample thickness, the absorption measurements allow extraction of the oscillator strengths of DMZ transitions in the solid Ar host. f values of 0.262 and 0.591 were determined for the $B \leftarrow X$ and $A \leftarrow X$ transitions, respectively, from the Gaussian fits shown in Figure 1, which compare well with the values of 0.302 and 0.475 observed in the gas phase.⁵ In contrast to the pure vibrational⁸ transitions of DMZ, presented in the following paper in this issue, the electronic transitions exhibit, as demonstrated in

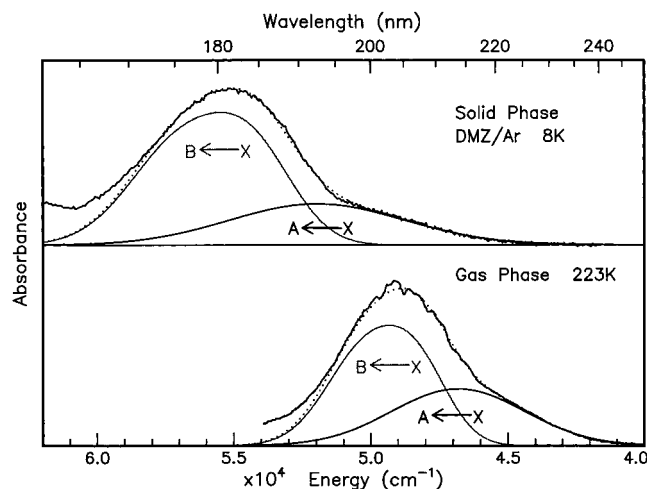


Figure 1. Absorption spectrum recorded at 8 K in the ultraviolet spectral region for a freshly deposited DMZ/Ar sample having a dilution ratio of 1/1000 (upper panel). Shown in the lower panel are the $B \leftarrow X$ and $A \leftarrow X$ electronic absorption transitions centered at 204 nm and extending up to 240 nm, respectively, as recorded at 223 K in the gas phase by Chen and Osgood.⁵

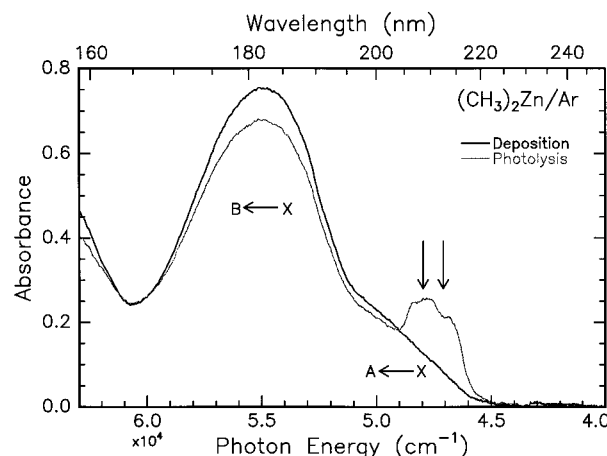


Figure 2. Absorption spectra, presented on a linear energy scale, of a matrix-isolated DMZ/Ar sample recorded at 8 K and prepared using a dilution ratio of 1/1000. The black trace was recorded upon deposition, while the gray trace was recorded after the DMZ/Ar sample was irradiated for 15 min with undispersed synchrotron radiation using an quartz optical filter.

Figure 1, blue shifts on the order of several thousand wavenumbers in the Ar matrix, if the gas-phase assignments are adopted.

The vibrational structure present on the gas-phase $B \leftarrow X$ absorption is clearly absent in the solid state even at the very low temperature (8 K) at which the spectra in Figure 1 were recorded. Luminescence of DMZ in the UV-visible spectral range, covered in the present study, was not detected as a result of photoexcitation with synchrotron radiation at the $B \leftarrow X$ or $A \leftarrow X$ transitions of DMZ/Ar shown in the upper panel of Figure 1.

B. Zeroth Order Photolysis. Photochemistry was examined initially by subjecting DMZ/Ar samples to undispersed synchrotron radiation using a quartz optical filter to select wavelengths longer than 155 nm. The effect of 15 min of this photolysis on the absorption profile is indicated by the gray trace shown in Figure 2. New features are observed between 205 and 220 nm in the red wing of the DMZ $A \leftarrow X$ absorption upon photolysis in conjunction with a decrease in the intensity of both DMZ bands.

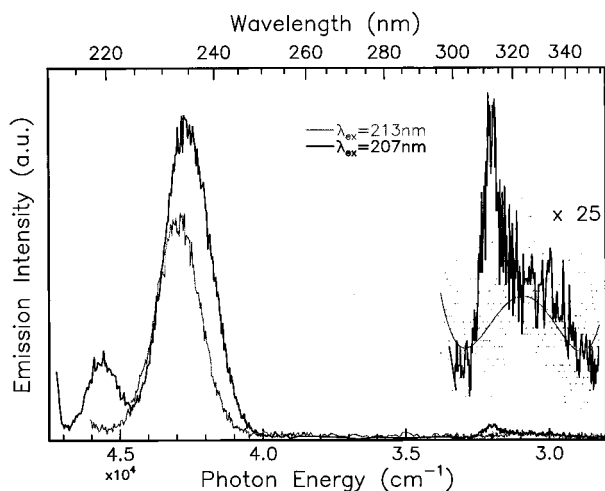


Figure 3. Luminescence spectra recorded at 8 K as a result of photoexcitation at 207 and 213 nm (indicated by the arrows in Figure 2) of the absorption features produced with photolysis of DMZ/Ar. The weak near-UV emission bands in the 300–340 nm spectral region are shown on an expanded vertical scale for ease of identification.

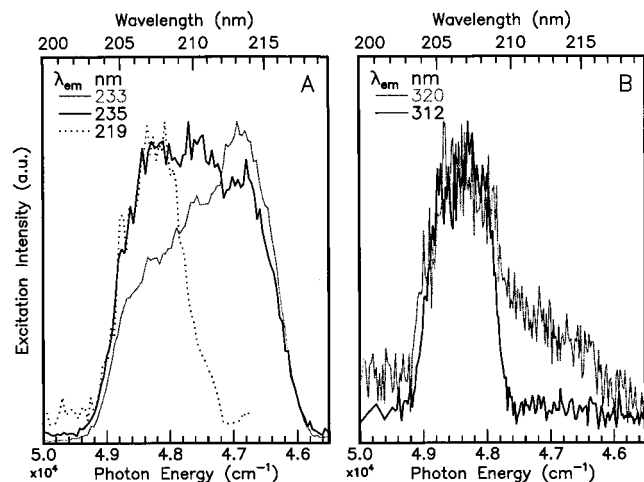


Figure 4. Excitation profiles recorded at 8 K by monitoring at the specified emission wavelengths of the photochemical fragments of DMZ matrix isolated in argon. In panel A, the excitation spectra of the UV emission bands are shown, while panel B contains the excitation spectra of the near-UV bands.

Emission spectra were recorded with photoexcitation, at the wavelengths indicated by the arrows in Figure 2, of the new absorption features produced as a result of the previously described photolysis of the freshly deposited DMZ/Ar sample. The emission spectra resulting from excitation at wavelengths of 207 and 213 nm are shown in Figure 3. Strong UV and weak near-UV emission bands are observed, whose maxima are observed to shift depending on the excitation wavelength used. The emission resulting from 207 nm excitation comprises a pair of UV bands at 219 and 235 nm and a much weaker near-UV feature at 312 nm. Excitation at 213 nm produces a single UV emission band at 233 nm and a broad, weak emission at 320 nm shown by the gray trace in Figure 3.

Excitation spectra recorded for the UV and near-UV emission bands presented in Figure 3 were observed to occur in the 205–220 nm spectral range, as shown in Figure 4. Panel A shows the excitation profiles of the UV 219, 233, and 235 nm emission bands, while panel B shows the excitation profiles of the weaker near-UV 312 and 320 nm emission bands. The excitation profile of the 233 nm emission extends from 202 to 218 nm, exhibiting a dominant feature at 213 nm, while that recorded for emission at 235 nm spans the same wavelength range but appears to

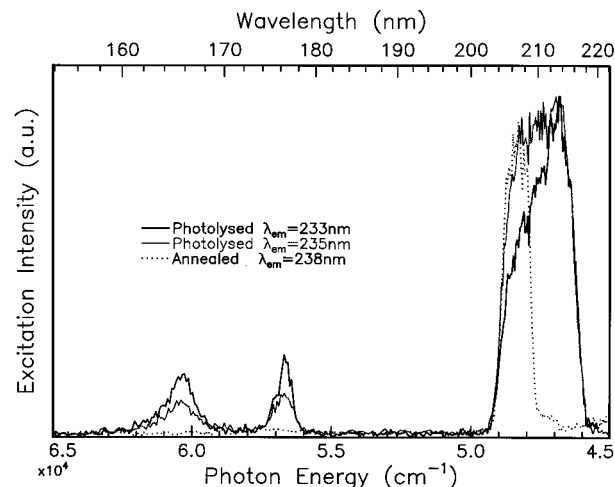


Figure 5. Higher energy excitation profiles recorded at 8 K for the indicated emission wavelengths of the photochemical fragments produced by zeroth-order photolysis of a 1/1000 dilution ratio DMZ/Ar sample. The effect of annealing on this photolyzed sample to 33 K for a 25 min period is shown by the dotted trace. Note that the composite excitation feature centered at 213 nm yields the structured band at 207 nm after annealing. In addition, the absence of the excitation features at 165 and 176 nm is noteworthy, as indicated by the dotted trace.

consist of three partially resolved features at 207, 210, and 213 nm. In contrast, a well-defined feature centered at 207 nm is observed when the 219 and 312 nm emissions are monitored as shown in panels A and B, respectively, of Figure 4. A broad excitation profile with a dominant feature located at 207 nm but extending up to 218 nm is recorded by monitoring emissions at 320 nm.

Figure 5 shows excitation profiles recorded for the previously mentioned 233 and 235 nm emission bands but scanned to higher photon energy than that presented in Figure 4. Two weaker excitation features are evident in Figure 5 at 165 and 176 nm in addition to the broad excitation profiles in the 205–220 nm spectral region described above. By exciting at wavelengths of 165 or 176 nm, emission spectra identical with that produced with 213 nm excitation were observed.

The observed decay time of the 235 nm emission resulting from 207 nm excitation, determined by fitting a double-exponential function to the temporal decay profile, had a value of 1.40 ± 0.14 ns. The minor (3%) component had a decay time of 0.2 ns. The temporal profile of the weaker 219 nm emission produced with 207 nm excitation resulted in a deconvoluted decay time of 0.89 ± 0.1 ns, which represented over 96% of the double-exponential fit. A decay time of 1.39 ± 0.14 ns was extracted from the decay curve of the 233 nm emission produced by excitation at 213 nm. The temporal decay of the near-UV emission features observed in the 310–350 nm region could not be measured with the TCSPC technique, even when the storage ring was operating in the “single-bunch” mode with a repetition rate of 1.042 MHz. This behavior is indicative⁹ of a long-lived emission having a lifetime greater than 10 μ s.

C. Photolysis (195 nm). The shapes of the 213/233 nm excitation/emission profiles were found to be strongly dependent on the type of photolysis done on DMZ. Thus, the excitation/emission profiles recorded for DMZ/Ar following photolysis at 195 nm for 45 min are shown in Figure 6 for the indicated wavelengths. Comparing the shapes of these excitation profiles with those shown in Figure 4, for zeroth-order photolysis of a DMZ/Ar sample, it is evident that the contributions of the 207 and 210 nm features are much reduced in the 195 nm photo-

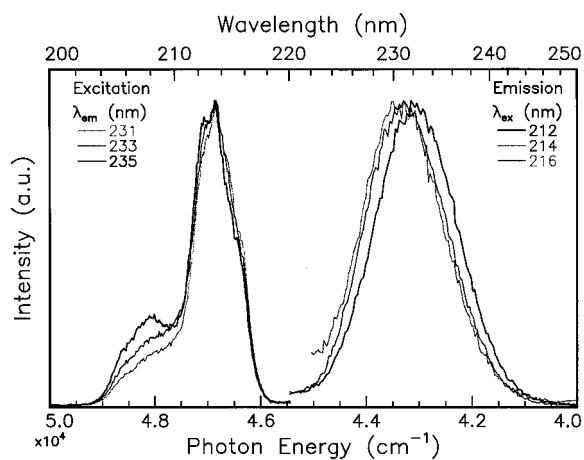


Figure 6. Excitation and emission spectra recorded at 8 K for a DMZ/Ar sample after prolonged (45-min) photolysis at 195 nm. Note the red-shift in the emission maxima as the photoexcitation energy is increased. Partially resolved features are evident at 212, 213.8, and 216 nm in the excitation profiles, exhibiting maxima dependent on the emission wavelength monitored.

lyzed samples, with the 213 nm band clearly dominating the excitation profile of the 233 nm emission. Hints of structure on the excitation profiles shown in Figure 6 are evident at 212, 213.8, and 216 nm. The complexity of the emission, shown on the right of Figure 6, is evident when these particular wavelength values are selected for photoexcitation. Conspicuously, the lowest energy excitation at 216 nm produces the highest energy emission centered at 230 nm, while the highest energy excitation at 212 nm yields the lowest energy band centered at 233 nm. Excitation at an intermediate energy of 214 nm produces an emission band of intermediate energy at 231 nm.

D. Methylzinc Radical. A careful examination was made for the production of methylzinc (ZnCH_3) upon photolysis of DMZ. This was pursued by monitoring the fluorescence⁴ of methylzinc in the 410–450 nm region by excitation of the $\tilde{A}^2E_{1/2} \leftrightarrow X^2A_1 0_0^0$ transition of ZnCH_3 , observed at 417.5 nm in the gas phase⁷ and having a radiative lifetime² of 47 ± 2 ns. No signal was obtained in this spectral range either with (a) wavelength-selected excitation/steady-state emission or (b) quartz-filtered zeroth-order excitation and monitoring time-gated emission in a 20–100 ns range. Thus, on the sensitivity of the present measurement, we must conclude from observation a that methylzinc is not permanently formed as a result of photodissociation of DMZ isolated in solid Ar and from b that it does not chemiluminesce if it is formed in an excited state from the dissociation of DMZ as has been reported in previous gas-phase vacuum UV measurements^{2,6} of dimethylcadmium using synchrotron radiation at wavelengths shorter than 205 nm.

E. Annealing. Annealing of photolyzed DMZ/Ar samples to 33 K for approximately 15 min resulted in pronounced changes in both excitation and emission spectra. In Figure 7, the effects of annealing on the excitation spectra of the UV and near-UV emissions of the photolyzed samples are shown. In the left panel of Figure 7, the broad composite profile, shown earlier in Figure 4, recorded by monitoring emissions at 235 nm of the photolyzed sample is no longer present, but a single feature centered at 207 nm and corresponding to the excitation profile of the 219 nm emission results. Closer examination of the annealed 207 nm excitation profile shown in black on the left in Figure 7 indicates the existence of a 3-fold splitting on this band.

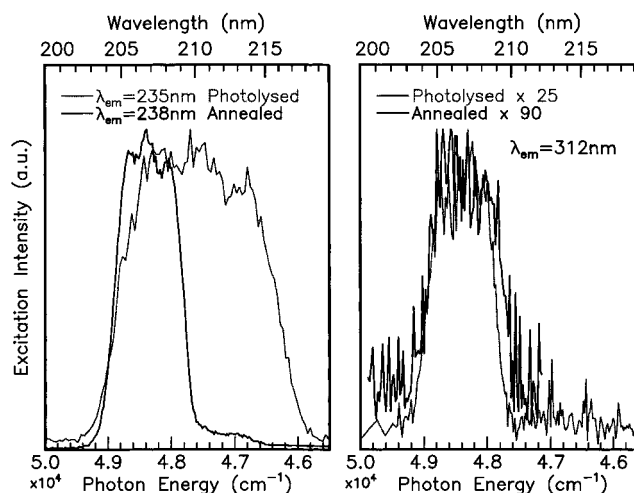


Figure 7. Excitation spectra (gray traces) recorded at 8 K for the UV 235 nm and near-UV 312 nm emissions, respectively, of a freshly photolyzed DMZ/Ar sample. The black traces correspond to excitation profiles recorded by monitoring the previously mentioned emissions but after sample annealing to 33 K for 25 min.

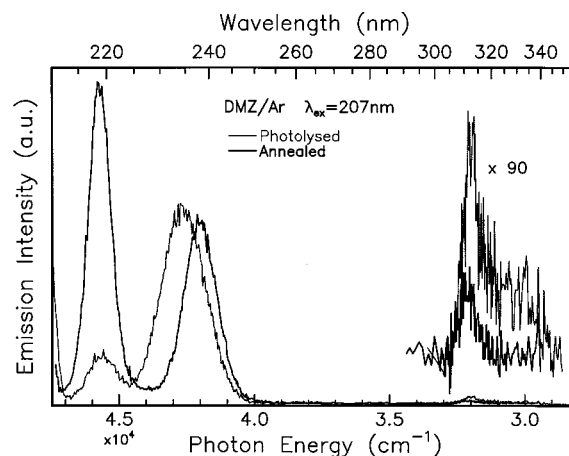


Figure 8. Emission spectra recorded at 8 K for a photolyzed DMZ/Ar sample and produced using a photoexcitation wavelength of 207 nm. The gray trace corresponds to the emission spectrum of a freshly photolyzed sample, while the black trace is the emission recorded in the same sample but annealed to 33 K for a period of 25 min.

Excitation into the central component of the 3-fold splitting at 206.7 nm produces the emission spectrum shown by the black trace in Figure 8. A pair of UV emission bands are observed at 218.7 and 238 nm, while a single band, weaker by a factor of 90, is observed in the near-UV at 312 nm. The emission bands recorded in the annealed sample (shown by the black trace in Figure 8) have a narrower bandwidth than those recorded for freshly photolyzed samples, shown by the gray trace in Figure 8. The excitation profiles of the two UV emission bands at 218.7 and 238 nm in the annealed sample are identical as shown by the upper traces in Figure 9. The spectral location of the excitation profile of the weaker 312 nm emission is, as shown on the bottom in Figure 9, the same as the UV profiles, but due to the weakness of the emission band and the resulting low signal-to-noise, the existence of splitting on the excitation band of the triplet can't be identified. However, given the similar spectral position and bandwidths of the singlet and triplet excitation bands, it is likely that the excitation profiles are the same. The excitation features present in freshly photolyzed samples at 165 and 176 nm were completely absent when 238 nm emission was monitored in the annealed samples, as depicted by the dotted trace in Figure 5.

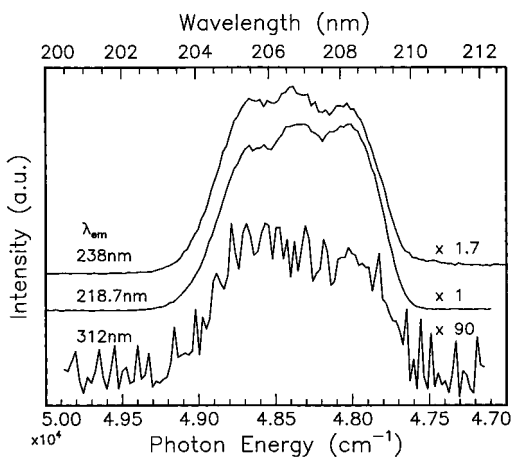


Figure 9. Comparison of the excitation spectra recorded for the three emission bands shown in Figure 8 present in DMZ/Ar samples first photolyzed and then annealed.

The decay time measured for the 218.7 nm emission as a result of 207 nm excitation was found from the TCSPC technique to be 0.92 ± 0.1 ns using a double-exponential fit of the decay profile. This value was found not to vary for samples below 9 K, prepared under the same conditions and composition, and contributed to over 97% of the decay profile. The decay profiles recorded for the 238 nm emission with 207 nm excitation exhibited an observed decay time of 1.43 ± 0.1 ns. Decay profiles of the 312 nm emission band could not be recorded with the TCSPC technique at an excitation repetition rate of 1.042 MHz, indicating⁹ a long-lived emission having a lifetime longer than 10 μ s.

IV. Discussion

A. Assignments of DMZ/Ar Absorption. Based on the similar band shapes and oscillator strengths of the DMZ absorption profiles, shown in Figure 1, recorded in solid Ar and in the gas phase, tentative assignments of the $B \leftarrow X$ and $A \leftarrow X$ transitions of DMZ in the matrix are made in accordance with those made by Chen and Osgood.⁵ It must, however, be remembered that a pronounced blue shift of 5600 cm^{-1} occurs in the matrix and, in contrast to the gas phase, no vibrational structure is observed on the $B \leftarrow X$ transition. Despite these differences, adoption of the gas-phase assignments to the matrix DMZ absorptions seems reasonable. With this assignment and on the basis of the theoretical analysis of Chen and Osgood,⁵ the unstructured A state of DMZ has a bent geometry, while the B state showing vibrational structure in the gas phase is linear. The large blue shifts on the two bands in the matrix can be traced back to the dominant Rydberg characteristics of the excited A and B states of DMZ. It is known from *ab initio* calculations² that the excited electronic states of DMZ have this characteristic and from previous matrix work¹⁰ on NO that Rydberg states exhibit such large blue shifts in the solid rare gases. This strong interaction between the DMZ guest and its host also explains the lack of vibrational structure on the $B \leftarrow X$ transition since the accompanying strong electron-phonon coupling will broaden the vibrational bands into a smooth profile.

B. Atomic Zinc Isolated in Annealed Solid Argon. A summary of the excitation and emission spectra recorded in the UV region for an annealed, previously-photolyzed DMZ/Ar sample is presented on the bottom in Figure 10. The upper excitation/emission profiles in Figure 10 were recorded for a sample prepared by the co-deposition of atomic zinc vapor with argon in a dilution ratio of $1/10^4$ and reported by us in a previous publication.⁹ Shown for comparison is the position of the $4s4p$

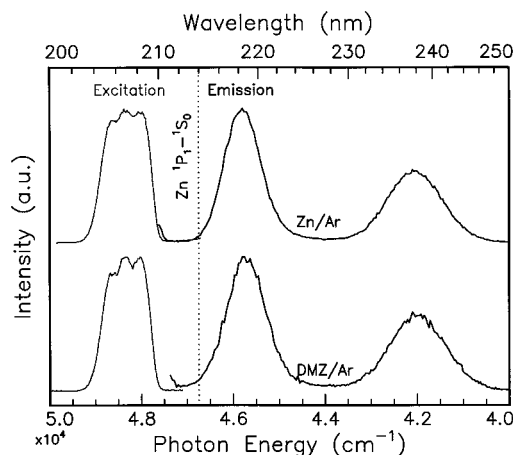


Figure 10. Excitation spectra recorded for the 218.7 nm emission in Zn/Ar and photolyzed DMZ/Ar samples are shown in gray on the extreme left-hand side. The emission spectra recorded at 8 K due to 207 nm excitation of the aforementioned samples are shown on the right-hand side in black. The position of the singlet resonance transition of atomic zinc in the gas phase is indicated by the vertical dotted lines for comparison.

$1P_1-4s^2$ $1S_0$ singlet resonance transition of atomic zinc in the gas phase. The excitation feature centered at 207 nm in Zn/Ar and photolyzed DMZ/Ar samples which exhibits a 3-fold splitting corresponds to the absorption spectra recorded by several groups¹¹ for zinc in argon and assigned to the $4s4p$ $1P_1 \leftarrow 4s^2$ $1S_0$ transition of Zn.

Observed decay times of 0.91 ± 0.1 and 1.43 ± 0.14 ns were recorded for the 218.7 and 238 nm emissions respectively due to excitation at 207 nm and found independent of temperature below 9 K. These values are identical within experimental error to those recorded by us⁹ for the UV emission bands in pure Zn/Ar samples and assigned to the singlet emission of atomic zinc in Ar. The presence of the pair of singlet emission bands has been attributed¹² to the co-existence of energetically distinct minima on the potential energy surface arising from Jahn-Teller coupling of the Ar lattice modes and the $4s4p$ $1P_1$ state of atomic zinc. Excellent agreement clearly exists between the steady-state and time-resolved measurements in pure Zn/Ar samples and the annealed, photolyzed DMZ/Ar samples, confirming the formation of atomic zinc as a dissociation product of the photolysis of DMZ in solid argon.

C. Triplet Emission. Although the singlet UV emissions of atomic zinc in Zn/Ar and photolyzed DMZ/Ar samples are very similar, the intensity of the emission at 312 nm was observed to be considerably enhanced in the photolyzed DMZ/Ar samples, because, as shown by trace A on the top in Figure 11, this band was not detected in the pure Zn/Ar samples. The spectral location and long ($>10 \mu$ s) decay time of the 312 nm emission strongly suggests that this band corresponds to the $4p$ $3P_1 \rightarrow 4s$ $1S_0$ phosphorescence transition of atomic zinc occurring at 307.6 nm in the gas phase¹³ and having a radiative lifetime¹⁴ of 30.4 μ s. Stronger Zn($3P_1$)/Ar emission was observed, as shown in trace C of Figure 11, in photolyzed DMZ/Ar samples in which the DMZ was not subjected to purification with freeze-pump-thaw (FPT) cycles. Such unpurified samples are known from IR absorption measurements⁸ to be contaminated with methane, and as a check of the role played by the hydrocarbon in the triplet enhancement, samples formed by the co-deposition of atomic zinc vapor with Ar doped with CH_4 and C_2H_6 were analyzed. The results are shown in the lower two panels of Figure 11.

It is evident in trace B of Figure 11 that the 312 nm band is present, albeit weak compared to the 5% alkane/Ar samples, in

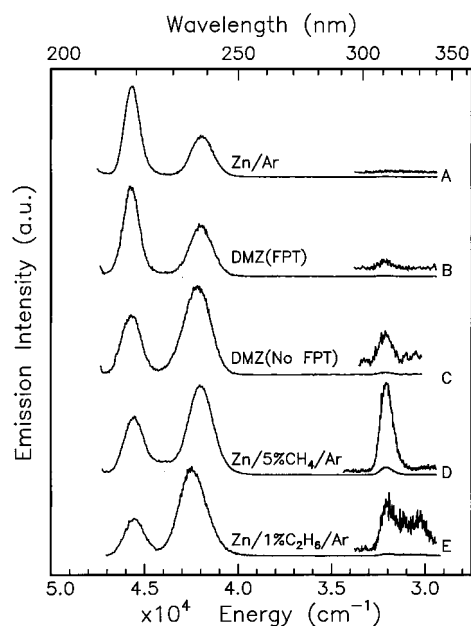


Figure 11. Emission spectra recorded as a result of atomic Zn excitation at 206.7 nm in pure Ar samples and matrices doped with the specified hydrocarbons indicating the increased intensity of the 312 nm band. Note the absence of the emission band in the pure Zn/Ar samples and its presence in photolyzed DMZ/Ar and hydrocarbon-doped Ar samples. The pair of triplet emission bands evident in trace E arise from different site occupancies of atomic zinc.

photolyzed DMZ/Ar samples prepared from purified DMZ. IR measurements show that no methane persists the FPT cycles, yet the enhancement of the triplet emission still exists in these DMZ/Ar samples. The reason for the enhancement is evident in the IR spectra⁸ of the annealed, previously photolyzed DMZ/Ar samples which show the growth of ethane bands upon annealing. In the bottom panel of Figure 11, the emission spectrum of a 1% ethane/Ar sample is shown, indicating the presence of the weak 312 nm band. The more intense triplet atomic zinc emission in photolyzed DMZ/Ar samples relative to pure Zn/Ar samples is explained in terms of the enhanced intersystem crossing occurring in the presence of hydrocarbon species¹⁵ in the former samples.

D. "Perturbed" Atomic Zinc. By exciting at 165, 176, and 213 nm in freshly photolyzed DMZ/Ar samples, identical emission spectra were produced with bands at 233 and 320 nm. Excitation at 207 nm produced emission bands at different positions, namely, a pair of UV emissions at 219 and 235 nm and near-UV emission at 312 nm as shown previously by the black trace in Figure 3. This behavior would suggest that one species is responsible for the 233-nm emission and a different species is responsible for the emissions at 219 and 235 nm. Examination of the excitation profiles of the UV and near-UV emissions shown in Figure 4 reinforces this suggestion. In particular, the similar excitation profiles centered at 207 nm recorded for emission monitored at 219 and 312 nm can, from a comparison of annealed DMZ/Ar samples and pure Zn/Ar samples,⁹ be attributed to atomic zinc fully isolated in the Ar lattice. In contrast to the 207 nm band, broad, ill-defined excitation profiles, extending over a larger wavelength range of 205–220 nm, were recorded when monitoring the 233 and 320 nm emissions also shown in Figure 4.

The decay times recorded for the 233 nm emission produced with excitation at 213, 176, or 165 nm were found to be identical, within the experimental error of the present lifetime measurements. Thus, these excitation features are assigned to transitions of a species distinct from that associated with the

207-nm excitation feature identified above as being atomic zinc fully isolated in Ar.

So far, the emission bands at 233 and 320 nm and their corresponding excitation spectra observed in freshly photolyzed samples have been attributed to a single species but are not assigned. The obvious candidates for assignment of this species are, in the order of their importance, clusters, site effects, or different photochemical products. Note that the species described above results from photolysis of DMZ monomer isolated in solid argon¹⁶ so that the cluster assignment can be ruled out immediately. Moreover, absorption spectra of zinc aggregates in solid neon¹⁷ and xenon¹¹ have been characterized and previously published. It is found that the spectral positions of low-order aggregates do not coincide with any of the bands observed in this study. The broad excitation features shown by panel A in Figure 4 between 205 and 220 nm and the features at 165 and 176 nm shown in Figure 5 disappear upon sample annealing, leaving only the 3-fold split excitation feature centered at 207 nm as shown in Figure 10. In a parallel FTIR study of DMZ/Ar photolyzed at 193 nm using an ArF excimer laser,⁸ methyl radical strongly perturbed by a neighboring species was identified at 730.4 cm⁻¹. Upon annealing, the perturbed methyl radical was observed to disappear with the concomitant production of the stable molecule¹⁸ ethane.

The luminescence spectroscopy of photolyzed DMZ/Ar samples recorded in the present study indicates the production of atomic Zn isolated in solid Ar upon sample annealing. Taking this in conjunction with the pronounced annealing effects observed in the IR study, the natural assignment of the 233/320-nm emission bands observed in the present UV luminescence measurements is a zinc atom interacting strongly with a nearby methyl radical but not forming a Zn–C bond to give methylzinc. The excitation features at 165, 178, and 213 nm of photolyzed DMZ/Ar samples, all of which have emission decay times similar to atomic zinc, disappear upon annealing, as evidenced in Figure 5, and are thereby ascribed to "perturbed" atomic zinc. The existence of a zinc atom in the presence of a very reactive methyl radical, which might initially seem surprising, will now be discussed. This species shall be referred to as "perturbed" atomic zinc throughout the remainder of this paper.

The co-existence of atomic zinc in the vicinity of two methyl radicals is realized because the zinc atom is formed in the unreactive ¹S₀ ground state. Based on valence bond theory, formation of a chemical bond between atomic zinc and the methyl radical requires hybridization of the 4s and 4p orbitals of atomic zinc. High-level *ab initio* calculations^{19,20} on ZnCH₃ verify this simple valence bond model, indicating predominant 4s(Zn) 4p_z(Zn) character in the highest occupied molecular orbital. Hybridization of the 4s/4p orbitals of atomic zinc in the low-temperature matrix is not feasible because the promotion energy required is far too great to be provided by the available thermal energy. Hence, the closed subshell electronic configuration of atomic zinc in the ¹S₀ ground state does not react chemically with the methyl radical to form the Zn–C bond in methylzinc, but its spectroscopy is strongly perturbed by a nearby methyl radical. This situation can be ascribed to the formation of the van der Waals complex Zn·CH₃. An important mechanistic consequence of the presence of the "inert" zinc atom positioned between the methyl radicals is that it impedes the latter's approach in the cylindrical divacancy site in the Ar lattice and thereby prohibits their recombination to form vibrationally excited ethane. This point will be elaborated upon in the section dealing with the photodissociation mechanism of DMZ in solid argon.

The complex nature of the 213/233 nm excitation/emission profiles, depicted in Figure 6, indicates that the perturbed species does not exist in a single form. In particular, the red-shifting of the emission maxima with increasing photoexcitation energy and the hint of structure on the excitation profiles indicates that homogeneous linewidths have not been recorded. It would appear from the excitation profiles that at least three forms of the perturbed $\text{Zn}\cdot\text{CH}_3$ complex are produced with the photodissociation of matrix-isolated DMZ. The origin of the triplication cannot be identified from the present IR or UV luminescence measurements, but the likely candidates would be different site occupancies or distinct separation or orientations of the methyl group and atomic zinc in the weakly bound $\text{Zn}\cdot\text{CH}_3$ complex.

In support of the perturbed Zn assignment, the absence in the present study of the methyl radical absorption at 150 nm, previously observed in solid argon by Milligan and Jacox,²¹ indicates that *isolated* methyl radicals are not produced from the dissociation of matrix-isolated DMZ. Furthermore, the predissociative methyl transition observed by Herzberg²² near 215 nm in the gas phase was not observed in the Ar matrix by Milligan and Jacox.²¹ Accordingly, the excitation features observed between 205 and 220 nm in a freshly photolyzed sample are not assigned to isolated methyl radical but to the $^1\text{P}_1 \leftarrow ^1\text{S}_0$ transition of atomic zinc perturbed strongly with a methyl radical. This assignment is consistent with the 1.40 ns lifetime observed for the 233 nm emission, a value identical to that recorded⁹ in pure Zn/Ar samples and which agrees well with the gas-phase radiative lifetime¹⁴ of 1.41 ns for the $^1\text{P}_1 \rightarrow ^1\text{S}_0$ transition of atomic zinc.

Examination of the higher energy levels of atomic zinc show that many states exist in the same region as the excitation features at 165 and 176 nm, none of which can be accessed by electric-dipole transitions from the $^1\text{S}_0$ ground state in the gas phase. Possible assignments for the 176 and 165 nm excitation bands may be the spin-forbidden $^3\text{S}_1 \leftarrow ^1\text{S}_0$ transition, occurring at 186.3 nm, and the parity-forbidden $^1\text{D}_2 \leftarrow ^1\text{S}_0$ transition at 163 nm. These transitions, strictly forbidden for the free zinc atom in the gas phase, may become partially allowed due to a lowering of symmetry in the perturbed $\text{Zn}\cdot\text{CH}_3$ complex generated upon dissociation of DMZ. In the truly isolated form of atomic Zn in solid Ar, cubooctahedral symmetry will exist for the Zn atom isolated in a single substitutional site in the Ar lattice, a situation more akin to the full rotational symmetry of the gas phase. Thus, it is expected that the transitions forbidden in the gas phase will also not be observed in annealed Ar samples.

E. Dissociation Mechanism. The quartz optical filter used in the zero-order photolysis selects wavelengths longer than 155 nm of the undispersed synchrotron radiation. Thus, energies of up to 184 kcal/mol are available to induce photodissociation of DMZ in the solid, but since only 63.7 kcal/mol is required to break the first zinc–methyl bond,²³ an excess of approximately 120 kcal/mol is available to break the second zinc–methyl bond of 25 kcal/mol! The energy made available by the type of UV photolysis applied is therefore much more than what is required to break both methyl–zinc bonds in either a sequential or a concerted fashion. Due to solid-state cage effects, however, direct cage exit of the cleaved methyl radical produced in the stepwise mechanism will be hindered, forcing it and methylzinc radical to occupy the same cage. Recombination of the methyl and methylzinc radicals will occur to regenerate DMZ. A concerted mechanism will, in contrast, be expected to achieve permanent dissociation, as the two methyl

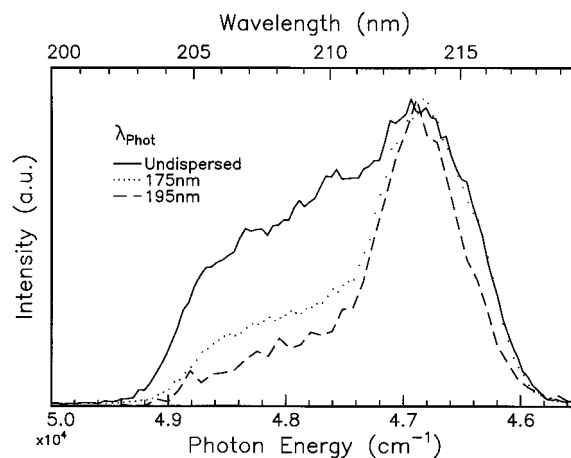


Figure 12. Excitation profiles recorded for the 233 nm emission of DMZ/Ar samples after 10 min photolysis at the specified wavelengths. Note the increasing intensity of the 207 nm feature as the photolysis energy is increased.

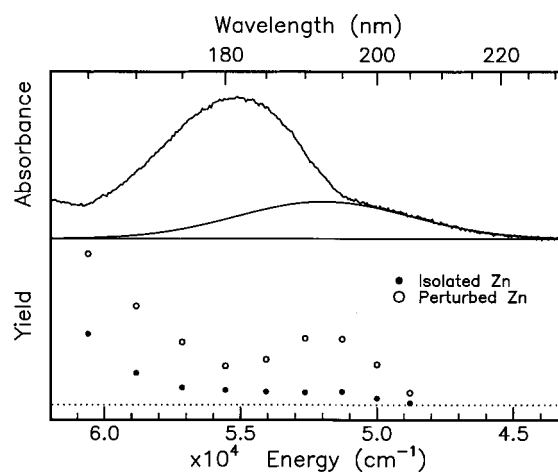


Figure 13. Growth curves obtained for the production of isolated atomic zinc (ex/em = 207/219 nm) and perturbed atomic zinc (ex/em = 213/233 nm) as a function of the photolysis energy. Shown in the upper panel is the absorption spectrum and spectral assignments of the $\text{B} \leftarrow \text{X}$ and $\text{A} \leftarrow \text{X}$ transitions of DMZ/Ar. Note the inefficiency of the direct production of isolated atomic until a photolysis wavelength of 180 nm is reached.

radicals will then be separated by an unreactive ground-state zinc atom.

The recorded excitation spectra indicate that only a small amount of atomic zinc exits the cage *directly*, facilitated by the 95 kcal/mol of excess internal energy resulting from the use of the quartz filter to select the photolysis wavelengths for the photodissociation of DMZ. When the kinetic energy of the fragments is lowered, by photolysis at 175 nm, the amount of isolated atomic zinc, centered at 207 nm, decreases dramatically, as shown in Figure 12. For photolysis wavelengths longer than 175 nm at 192 and 200 nm, the production of truly isolated atomic zinc is much reduced. Therefore, it would appear that little direct cage exit of atomic Zn occurs at these lower energies.

Growth curves indicating the yields of isolated atomic zinc and perturbed atomic zinc as a function of photolysis wavelength are presented in Figure 13 along with the absorption profile of DMZ/Ar. The growth curve of the perturbed species is prompt, showing a maximum at around 193 nm and showing a second onset for wavelengths shorter than 180 nm. In contrast, the yield of isolated atomic zinc is negligible until around 175 nm (163.4 kcal/mol), thereafter increasing steadily to the quartz cut-

off. From a comparison of these growth curves with the absorption profile, shown in the upper panel of Figure 13, it appears that the production of the perturbed atomic zinc species follows the A-state absorption profile. In contrast, the production of isolated atomic zinc has a threshold at 175 nm on the blue wing of the B-state absorption.

On the basis of the spectral assignments made in section A of the Discussion section, one would expect, as observed experimentally for dimethylcadmium,⁶ that the bent A state would be more likely to produce translationally hot atomic zinc than the B state, with its linear geometry. From a comparison of the fragment growth curves and the absorption curves shown in Figure 13, the opposite behavior is exhibited in the matrix. This difference is probably a reflection of the influence the surrounding host matrix has on the production of the isolated fragment atomic zinc, requiring a very large excess of dissociation energy for the direct production of such a species.

Assuming that all the excess internal energy goes into the kinetic energy of the escaping Zn atom, then the energy threshold for direct cage escape of atomic Zn from the growth curve in Figure 12 is between 75 and 60 kcal/mol. If, more realistically, it is assumed that equal partitioning of the excess internal energy occurs between the three fragments—the two methyl radicals and the zinc atom—then a threshold range of between 25 and 20 kcal/mol is obtained. Having no energetically accessible internal degrees of freedom, all of this energy will go into the kinetic energy of the Zn atom, while in the methyl groups it must be shared with vibrational excitation. This may explain why the methyl groups do not escape from the original site of isolation while the Zn atom does.

During sample annealing, the increased thermal energy and expansion of the host's lattice facilitates the mobility of photochemical fragments and the possible recombination of the two methyl radicals. Expansion of the host's lattice allows enough space within the divacancy site originally occupied by the parent DMZ molecule for the two methyl radicals initially separated by the inert zinc atom to approach and combine. From gas phase²⁴ and theoretical work,²⁵ it is known that direct recombination of methyl radicals occurs without any activation energy barrier to produce ethane, with 87.6 kcal/mol of vibrational excitation.²⁶ The FTIR study of DMZ/Ar which follows indicates that this excess energy is dispersed through two channels, namely, stabilization of ethane by energy dissipation to the lattice or further dissociation to form the new products²⁷ ethylene and molecular hydrogen. Supporting the IR observations, molecular hydrogen gas has been monitored by mass spectrometry escaping from the Ar lattice during annealing in this study.

V. Conclusions

Using steady-state and time-resolved optical luminescence spectroscopy, the photochemical fragments atomic zinc perturbed by a nearby methyl radical and truly isolated atomic zinc have been identified from the photodissociation of DMZ in an argon matrix. Excitation spectra of truly isolated atomic zinc in an argon matrix show a 3-fold splitting attributed to the dynamical Jahn–Teller effect. These splittings are identified as the matrix equivalent of the gas-phase $4p\ ^1P_1 \leftarrow 4s\ ^1S_0$ resonance transition of atomic zinc. From a combination of luminescence spectroscopy and time-resolved measurements, singlet and triplet transitions were assigned respectively to the pair of UV emission bands at 218.7 and 238 nm and a near-UV emission band at 312 nm of matrix-isolated zinc in argon.

A concerted loss mechanism of the methyl groups is ascribed as being responsible for the permanent photodissociation of

DMZ in solid Ar. It is proposed that both methyl radicals occupy the extreme positions in the divacancy site originally occupied by the parent DMZ molecule, with the perturbed zinc atom positioned between. Atomic zinc is unreactive with respect to the methyl radicals because it is formed in the 1S_0 ground state, a closed subshell electronic configuration allowing it to co-exist in the vicinity of a methyl radical. This proposal is confirmed by a complementary FTIR study of DMZ/Ar,⁸ where the species methyl radical strongly interacting with a nearby zinc atom has been characterized. The photochemical fragment methylzinc radical may be produced, but due to solid-state cage effects, the first cleaved methyl radical is hindered from exiting the cage. Thus, geminate recombination of the methyl and methylzinc radicals occurs, regenerating the DMZ molecule in the matrix cage.

In the case of high-energy photolysis ($\lambda < 175$ nm) of DMZ/Ar, direct cage exit of the zinc atom is facilitated with an equal three-way partitioning of the excess energy between the two methyl radicals and a zinc atom. The two remaining photofragment methyl radicals occupy the original site of isolation of the DMZ molecule and subsequently combine along a barrierless surface to form ethane. Small amounts of ethane were produced as indicated by triplet emission enhancement for samples of atomic zinc isolated with different concentrations of ethane dopant in argon matrices. An enhancement in the relaxation of the singlet excited state of atomic zinc to the triplet occurs in the presence of the ethane. This ISC competes very efficiently with chemical quenching of singlet excited zinc which, as presented in the following paper in this issue, results in the insertion of a zinc atom into a C–H bond of ethane to form ethylzinc hydride. Although a definite mechanism for the ISC enhancement in the presence of the hydrocarbons has not been established, it is proposed, as observed in earlier Mg/CH₄ work,²⁸ that the enhanced production of triplet emission is a result of the initially attractive inserted reaction coordinate.

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